L Number	Hits	Search Text	DB	Time stamp
-	17	"resist application" with semiconductor with substrate	USPAT;	2004/06/15 14:18
ļ	••		US-PGPUB	
ļ -	1	("resist application" with semiconductor with substrate) and	USPAT;	2004/06/15 14:18
		hmds	US-PGPUB	
-	146	"resist application" with substrate	USPAT;	2004/06/15 14:46
		· ·	US-PGPUB	
-	7	("resist application" with substrate) and hmds	USPAT;	2004/06/15 14:18
			US-PGPUB	0004/00/45 44 47
ļ -	21944	(resist or photoresist or "photo resist") with (applicat\$4 or	USPAT;	2004/06/15 14:47
	024	coat\$3) with (substrate or wafer) ((resist or photoresist or "photo resist") with (applicat\$4 or	US-PGPUB USPAT:	2004/06/15 14:47
-	924	coat\$3) with (substrate or wafer)) and hmds	US-PGPUB	2004/00/13 14.47
	4	(((resist or photoresist or "photo resist") with (applicat\$4 or	USPAT:	2004/06/15 14:48
_	7	coat\$3) with (substrate or wafer)) and hmds) and	US-PGPUB	2004/00/10 14.40
		dehumidified	00-1 01 05	
_	11	("5571560" "5626913" "5658615" "5695817" "5720814"	USPAT	2004/06/16 08:29
	''	"5919520" "5962070" "5972426" "6162507" "6234692"		
i		"6241403").PN.		İ
-	3677	((427/240) or (427/314) or (427/444) or (438/782) or	USPAT;	2004/06/16 08:56
		(438/780) or (438/905)) CCLS.	US-PGPUB	
-	272	(((427/240) or (427/314) or (427/444) or (438/782) or	USPAT;	2004/06/16 09:01
1		(438/780) or (438/905)).CCLS.) and (((pre or preliminary)	US-PGPUB	
1		with (treatment or treating or treated)) or "pre-treatment" or		
		"pretreatment")		
-	8	(((427/240) or (427/314) or (427/444) or (438/782) or	USPAT;	2004/06/16 09:08
		(438/780) or (438/905)).CCLS.) and ("de-humidified" or	US-PGPUB	
	445	"dehumidified")	LIODAT	0004/00/40 00:00
-	115	(((427/240) or (427/314) or (427/444) or (438/782) or	USPAT; US-PGPUB	2004/06/16 09:09
		(438/780) or (438/905)).CCLS.) and (humidity with (control\$4	US-PGPUB	
_	11	or reduc\$4)) ((((427/240) or (427/314) or (427/444) or (438/782) or	USPAT:	2004/06/16 09:09
-		(438/780) or (438/905)).CCLS.) and (((pre or preliminary)	US-PGPUB	2004/00/10 00:00
		with (treatment or treating or treated)) or "pre-treatment" or	00 1 01 02	
		"pretreatment")) and ((((427/240) or (427/314) or (427/444) or		
		(438/782) or (438/780) or (438/905)).CCLS.) and (humidity		
1		with (control\$4 or reduc\$4)))		
1-	3		USPAT	2004/06/16 10:20
		"2002/0025375").PN.		
1-	3	("5143552" "6306455" "6326597" "2001/0044161"	USPAT	2004/06/21 09:38
	_	"2002/0025375").PN.		0004/00/04 00 00
-	2	(resist or "photoresist") with (dehumidified or "humidity	USPAT;	2004/06/21 09:39
	4	controll")	US-PGPUB	2004/08/24 00:40
-	4	((resist or "photoresist") with (dehumidified or "humidity	USPAT; US-PGPUB	2004/06/21 09:40
_	17	control")) and hmds (resist or "photoresist") with (dehumidified or "humidity	USPAT;	2004/06/21 09:44
'	''	(resist of photoresist) with (dendmidified of harmary	US-PGPUB	230-1100/21 00:44
-	2	(resist or "photoresist") with (dehumidified or "humidity	EPO; JPO	2004/06/21 09:46
	_	control")		
-	13	(resist or "photoresist") and (dehumidified or "humidity	EPO; JPO	2004/06/21 09:46
]		control")		
-	11	("5571560" "5626913" "5658615" "5695817" "5720814"	USPAT	2004/06/21 10:05
		"5919520" "5962070" "5972426" "6162507" "6234692"		
		"6241403").PN.		
L <u>-</u>	0	6458208.URPN.	USPAT	2004/06/21 10:26